In the United States Patent and Trademark Office

Serial No. 10/550,855	§ §	Filing date: 09/18/2006	
Title: FORMATION OF THIN SEMI- CONDUCTOR LAYERS BY LOW-	\$ §	Examiner: McCall Shepard, Sonya D	
ENERGY PLASMA ENHANCED CHEMICAL VAPOR DEPOSITION	\$ §	GA No.: 1734	
AND SEMICONDUCTOR HETERO- STRUCTURE DEVICES	§ §	Confirmation No. 3611	
Applicant: VON KAENEL, Hans	§ §	Atty docket No: PUS-E005-013	
CERTIFICATE OF TRANSMISSION UNDER 37 CI transmitted to the Patent and Trademark Office, as	FR §1.8	I hereby certify that this correspondence is being facsimile pages, total,	
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ELECTION OF SPECIES

Via facsimile to 001-571-273-8300, to:

Commissioner for Patents P. O. Box 1450 Alexandria, Virginia 22313-1450 U.S.A.

Dear Sir,

Applicant thanks the Office for the Restriction Requirement dated March 24, 2009, and in response thereto, Applicant elects, without traverse, Group I, which reads on claims 1-17, for further prosecution.

The Undersigned authorizes the Commissioner to charge any fee or credit any overpayment of any fee under 37 CFR §1.16 which may be required in this application, to the deposit account of MOETTELI & ASSOCIES SARL, No. 50-2621.

If the Examiner has further questions, she is invited to contact the undersigned by email at moetteli@patentinfo.net (preferred) or by phone at 202-204-2222.

Respectfully submitted,

s/john moetteli/

John Moetteli

U.S. Reg. No. 35,289

Date: April 23, 2009